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THE UNITED STATES PATENT AND TRADEMARK OFFICE

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|--|---|------------------------------|
| In re application of: | § | |
| Huan-Just LIN, et al. | § | Confirmation No. 9213 |
| | § | |
| Serial No.: 10/688,045 | § | Group Art Unit: 1722 |
| | § | |
| Filed: October 17, 2003 | § | Examiner: Robert M. Kunemund |
| | § | |
| For: Fully Dry, Si Recess Free Process for | § | |
| Removing High K Dielectric Layer | § | |

Commissioner for Patents
Mail Stop Amendment
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT

Sir:

A check is enclosed for \$130 for a terminal disclaimer. No additional fees, including extension of time fees, are believed necessary for consideration of the present paper. However, if any fees, including extension of time fees, are necessary, the extension of time is hereby requested, and the Commissioner is hereby authorized to charge any fees, including those for the extension of time, to Haynes and Boone, LLP's Deposit Account No. 08-1394.

In response to the Office action of November 25, 2005, please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on **page 2** of this paper.

Remarks begin on **page 9** of this paper.